The Analysis of Coulomb Blockade in Fullerene Single Electron Transistor at Room Temperature

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ABSTRACT
The Graphene based single electron transistor (SET) as a coulomb blockade device need to be explored .It is a unique device for high-speed operation in a nano scale regime. A single electron transfers via the coulomb barriers, but its movement may be prevented by coulomb blockade, so its effect is investigated in this research. The conditions of coulomb blockade and its controlling factors such as material, temperature, gate voltage and island length are investigated. At first, the coulomb blockade on fullerene SET as a nano transistor with new material is modeled and compared with experimental data of silicon SET. The comparison study indicates that the coulomb blockade range of fullerene SET is lower than the silicon one. On the other hand, the analysis demonstrates that, temperature and gate voltage play direct associations with zero current SET. In addition, island length and its material effect on coulomb blockade and desired current are achieved by decreasing the coulomb blockade range.

Keywords: Gate voltage, Coulomb blockade, Island length, Fullerene, Single electron transistor
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INTRODUCTION
The Coulomb blockade effect (CB) as an operational principle of single electronic devices has been discussed by C. Gorter for the first time [1]. His research result has expressed that the current was suppressed in low bias voltage because of the coulomb repulsion. This phenomenon has been explained by single electron tunneling and formulated by D. Averin and K. Likharev as the orthodox theory in 1985[2]. After the description of orthodox theory, the experiments about single electron devices have been increased and led to the building of the first single electron transistor (SET) with metallic island by Dolan and Fulton in 1987[3]. It has worked from 1.1 °K to 4.2 °K that highlights the SET limitation at room temperature operation. This limitation has been improved by using silicon island in SET fabrication 1997[4] that cleared the effect of island material on the SET operation which plays a key role on solving the limitation of SET. Therefore island SET was made of new materials such as graphene as a new carbon
base material in 2010 [5, 6]. On the other hand, electrical property of island material, for example carrier mobility and electron transport plays effective roles in SET operation and suppression of coulomb blockade. In this research, fullerene material is selected as an island material due to its ballistic transport and high electron mobility [7, 8]. In the selected structure the SET includes an island between three electrodes named as source, drain and gate. Which contains two tunnel junctions that each tunnel junction is equivalent to a tunnel resistance and a tunnel capacitance as shown in figure 1 [9, 10].

![Fig. 1. Single electron transistor.](image1.png)

The electrons tunnel to or out of the island through a tunnel junction. When the first electron passes from a tunnel junction, then the tunnel capacitance is charged. It prevents the second electron tunneling to the island until the first electron leaves the island because the island charge is higher than the bias voltage. This phenomenon can stop the transition of the electron which is called coulomb blockade. Another condition of coulomb blockade will occur if the thermal energy “K_B T” is higher than the charging energy (The essential energy for moving an electron to the island). Moreover tunneling resistance “R_t” less than 25813Ω causes the coulomb blockade effect as well [11-15]. The electron transport is controlled by energy levels, therefore the energy level diagrams of coulomb blockade and a single electron tunneling are shown in figure 2.

![Fig. 2. (a) Coulomb blockade condition happened and the electron doesn't transfer to the island. (b) The electron tunneling occurs and the electron transfers to the island.](image2.png)

In the other words the coulomb blockade condition occurs when the energy level of the island is higher than the source Fermi level and then the electron can't tunnel to island as shown in figure 2-a, but if the energy level of the island is lower than source Fermi level, the electron will move to island and electron tunneling can occur as displayed in figure 2-b. Therefore the current flows by single electron tunneling via the tunnel barriers.
in SET. Its current–voltage characteristic is plotted in figure 3. This curve has a coulomb blocked range, and both conductance and current are zero in the coulomb blocked region. The investigation of SET I-V curve indicates that Fermi level of source is equal to the drain Fermi level in the origin as illustrated in figure 3-a, because any bias voltage isn’t applied to SET. Fermi levels of two electrodes are changed by applying voltage as shown in figure 3-b, but electron tunneling to island needs an unoccupied energy level between their Fermi levels as displayed in figure 3-c [16].

![Fig. 3. I-V characteristic of SET. (a) The unequipped energy level is higher than the source Fermi level and coulomb blockade condition occurs. (b) Electrodes Fermi level is changed by applying voltage, but the unequipped energy level is higher than source Fermi level and then coulomb blockade condition occurs. (c) The source Fermi level is equal to an unequipped energy level, therefore an electron transfer to the island.](image)

**Modelling**

The electron tunneling process has been expressed by a master equation which indicates the change of free energy, background charge ($q_0$) and the number of electrons in island ($N$) play important roles in transistor operation. The free energies of two tunnel junctions can be written as

$$\Delta F_1^\pm(\eta_1, \eta_2) = \frac{e}{2} \sum \{ (N_1 - q_0) \Delta (C_1 + C_2) - \Delta C_G \}$$

(1)

Where $\Delta F_1^\pm$ and $\Delta F_2^\pm$ are the free energies of left and right tunnel junctions, respectively. Moreover $C_G$ is gate capacitor, $C_1$ and $C_2$ are capacitors of either left or right tunnel barriers. The electron can transfer from left to the right direction which is “+” and the right to the left direction is “−”. Then electron tunneling rate can be calculated as

$$\Gamma_2^\pm(N) = \frac{e}{2} \sum \frac{-\Delta F_2^\pm}{R_2 e^2} \left[ 1 - \exp\left( \frac{-\Delta F_2^\pm}{K_B T} \right) \right]$$

(2)

By attention to the electron tunneling rate, the current as a function of voltage has been addressed as [17].

$$I(V) = e \sum_{N=-\infty}^{\infty} \rho(N) \{ \Gamma_1^-(N) - \Gamma_1^+(N) \}$$

$$= e \sum_{N=-\infty}^{\infty} \rho(N) \{ -\sum_{N=-\infty}^{\infty} \Gamma_1^+(N) + \sum_{N=-\infty}^{\infty} \Gamma_1^-(N) \}$$

(3)
SET works by electron tunneling between different parts of SET such as island and tunnel junctions as marked in figure 4-a. On the other hand, transmitting waves from several regions are expressed with different wave functions by Schrödinger’s equations[18]. Furthermore SET energy as a function of channel length is shown in figure 4-b.

SET has two tunnel junctions which first and the third regions have similar Schrödinger’s equations, but island Schrödinger’s equation is different from other regions and their equations are expressed respectively as

\[ \psi_1(x) = A_1e^{ik_1x} + B_1e^{-ik_1x} \quad \text{Where} \quad k_1 = k_3 = \frac{\sqrt{2m(E)}}{\hbar} \]  

\[ \psi_2(x) = A_2e^{ik_2x} + B_2e^{-ik_2x} \quad \text{Where} \quad k_2 = \frac{\sqrt{2m(V-E)}}{\hbar} \]  

Based on the proposed condition, the transmission coefficient of fullerene SET has been reported by

\[ T = \frac{\text{me}^{(E-E_g)}}{\text{m}e^{(E-E_g)} + 0.0625(2mE_0 + 2(E-E_g)\hbar^2)^2 + 2a^2s \text{ sinh}^2(\sqrt{\frac{2(E-E_g)^2}{\hbar^2}})} \]  

Where “\( E_g \)” is energy band gap of fullerene, “\( E \)” is energy of fullerene, “\( m \)” is effective mass, “\( \hbar \)” is plank constant, Eta is \( \eta = \frac{E_g - E}{K_BT} \) “\( T \)” is temperature, “\( K_B \)” is Boltzmann constant , “\( L \)” is length of island, \( a_{cc} = 1.42\text{Å} \) is carbon-carbon bond length and \( t = 2.7\text{eV} \) is the nearest neighbor carbon-carbon tight binding overlap energy, also to calculate the drain quantum current based on the Landauer formalism as the well-known current expression can be used and current is modeled as [19, 20].

\[ I_d = \frac{4\sqrt{2}\eta(E_g - E_0)^2/(\hbar^2 + 2a^2s)^2 \text{ sech}(\sqrt{\frac{2(E-E_g)^2}{\hbar^2}})}{4\sqrt{2}\eta(E_g - E_0)^2/(\hbar^2 + 2a^2s)^2} \]  

Where \( T(E) \) is transmission coefficient of fullerene SET and \( \eta = \frac{E_g - E}{K_BT} \) \( d = \frac{E_g}{K_BT} \), \( x = \frac{E - E_g}{K_BT} \) and \( \eta = \frac{E_g - E}{K_BT} \) also “\( m \)” is effective mass, “\( \hbar \)” is plank constant , \( a_{cc} = 1.42\text{Å} \) is carbon-carbon bond length, \( t = 2.7\text{eV} \) is the nearest neighbor carbon-carbon tight binding overlap energy , \( T \)” is temperature, “\( K_B \)” is Boltzmann constant and “\( L \)” is island length. To evaluate the proposed model, the current-voltage characteristics of the suggested model and experimental data that are extracted from published data are compared in figure 5 [7].

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The proposed model and experimental data are compared with each other and an acceptable
agreement is reported [7]. Moreover, the effect of island length on coulomb blockade range is investigated as shown in figure 6. The different island lengths are compared with each other, which shows that island length has a direct effect on coulomb blockade range, and more the island length indicates a bigger coulomb blockade region.

Furthermore, the gate voltage has a notable effect on the coulomb blockade region as shown in figure 7. In attention to the curves of figure 7, it is clear that increasing the applied gate voltage leads to an incremental effect on coulomb blockade range, so this parameter can control the zero current region.

Based on the presented model, the temperature as an important factor in the SET operation mechanism is explored as shown in figure 8. The result of the temperature up to the room temperature expresses that coulomb blockade range decreases with increasing the temperature.

May be it is not the cause to compare the I-V characteristic of fullerene SET by silicon one however to get some senses about its importance, the analysis of I-V characteristic is carried out as shown in figure 9. It is demonstrated that the coulomb blockade range is observed in silicon SET between the drain biases from 0 V to 0.7 V [21] and there is a millivolt of coulomb blockade range in fullerene SET. This analysis again highlights that fullerene SET has lower coulomb blockade range than silicon SET as shown in figure 9 which indicates the higher operating speed and better performance.
range than the conventional silicon family. Therefore fullerene SET with better operational performance as a replacement of silicon needs to be explored.

CONCLUSION

Single electron transistor (SET) based on graphene as a nano scale transistor, operates by coulomb blockade effect, that cuts transferring of single electron between coulomb barriers, which causes zero current in SET I-V characteristic. In the presented work coulomb blockade current on fullerene based SET is modeled and the obtained results are compared with the silicon SET. It is concluded that the coulomb blockade range of fullerene SET is lower than the silicon one. Moreover island length, gate voltage and temperature have direct effects on zero current range of fullerene SET. In other words, coulomb blockade can be controlled by these parameters in fullerene SET as well. Additionally, millivolt of coulomb blockade range in fullerene SET is observed, which supports the silicon SET replacement in future nanotechnology.

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CONFLICT OF INTEREST

There is not any conflict of interest.

REFERENCES